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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Applicant:

Pei-Yang Yan

Serial No.: 10/631,171

Filed: July 31, 2003

For: Multilayer Reflective Extreme
Ultraviolet Lithography Mask Blanks

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Art Unit: 1756

Examiner: Stephen D. Rosasco

Docket: ITL.0952US
P15976

Assignee: Intel Corporation

Mail Stop **Amendment**
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REPLY TO PAPER NO. 20050420

Sir:

In response to the office action mailed May 5, 2005, reconsideration is requested in view of the following remarks.

Date of Deposit: June 30, 2005
I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.
Cynthia L. Hayden
Cynthia L. Hayden